Influence of High Pressure Rinsing

Prior to Mid-T Heat Treatment

Rezvan Ghanbari, on behalf of SRF R&D and DESY Nanolab teams













Tuning the interstitial oxygen concentration of mid-T heat treated cavities

By the number of HPR cycles before the heat treatment

- Mid-T heat treatment (3-20 h @ 200-400°C in UHV) improves Q_0 and changes dQ_0/dE_{acc}
- Oxygen concentration is the key parameter for mid-T heat treatment
- HPR affects pentoxide growth



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- XPS measurements are done with the same voltage and condition
- penetrate **the first 5 nm** of the sample surfaces
- Deconvolute the spectra with known oxide layer structure



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Extensive HPR grows thicker and mid-T heat treatment causes thinner pentoxide

X-Ray Photoelectron Spectroscopy (XPS)



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	X-Ray Photoelectron Spectroscopy (XPS)						
	0 HPR cycle	6 HPR cycles	18 HPR cycles	s			
<i>Nb</i> ₂ <i>0</i> ₅	~13.0	~17.0	~40.9				
Other oxides Nb	~3.7	~3.6	~4.8				

The first **5** *nm* of the surface

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	X-Ray Photoelectron Spectroscopy (XPS)								
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				Mi	Mid-T heat treatment				
<i>Nb</i> ₂ <i>O</i> ₅	~13.0	~17.0	~40.9	~10.9	~14.0	~15.0			
Other oxides Nh	~3.7	~3.6	~4.8	~3.2	~4.5	~5.8			

The first **5** *nm* of the surface

0

0)

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HPR prior to mid-T heat treatment changes the oxygen concentration after heating

• Samples with HPR cycles have different oxygen

distribution compared to no-HPR sample



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Conclusions

- Higher number of HPR cycles grows thicker pentoxide layer
- Higher number of HPR cycles prior to mid-T heat treatment causes different oxygen distribution

- How does the performance of a cavity change with higher number of HPR prior to mid-T heat treatment?
- Is the increased oxygen concentration enough to alter the performance?
- Is more oxygen beneficial or detrimental?





Thanks for your attention



Any questions?

Rezvan Ghanbari Institute of Experimental Physics E-Mail: rezvan.ghanbari@desy.de Phone: (+49) 040-8998-4321 I would like to express my thanks to:

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BACKUP



Mid-T heat treatment

